

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:

XU, GU et al.

Serial No.: 10/084,287

Filed: February 25, 2002

PHOTOSENSITIVE RESIN

COMPOSITIONS FOR COLOR FILTER

APPLICATIONS

Docket No.: 30108-DIV1

Group Art Unit No.: 1711

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Examiner: S. Berman

Assistant Commissioner of Patents Washington, D.C. 20231

Sir:

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The attached references is being filed to fulfill the duty of candor and good faith toward the Patent and Trademark Office, as required by 37 C.F.R. §1.97(c) and 37 C.F.R. §1.17(p).

Any fee which is due in connection with this Statement should be applied against Deposit Account No. 19-0522.

Respectfully submitted,

Bv

Tracy Bornman, Reg. No. 42,347

HOVEY WILLIAMS LLP

2405 Grand Boulevard, Suite 400 Kansas City, Missouri 64108

(816) 474-9050

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U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO. 30108-DIV1

SERIAL NO. 10/084,287

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

APPLICANT: XU, GU et al.

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(Use several sheets if necessary)

FILING DATE:

GROUP: 171 1 5 700

February 25, 2002

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U.S. PATENT DOCUMENTS

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FOREIGN PATENT DOCUMENTS

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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	Declaration of Jonthan Mayo executed June 14, 2002 (5 pages), with Exhibits A-G (17 pages)

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.